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PATENT 30205/39513

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicants: Young Sun Hwang et al.) I hereby certify that this paper and the
Serial No.: 10/719,083	documents referred to as enclosed therewith are being deposited with the United States Postal Service as first class mail, postage prepaid, on August 4, 2005 in an envelope addressed to MS Amendments, Commissioner for Patents, P.O. Box 1450, Alexandria, Virginia 22313-1450 Michael R. Hull Reg. No. 35,902 Attorney for Applicant
Filed: November 21, 2003	
For: Methods for Forming Fine Photoresist Patterns	
Group Art Unit: 1765	
Examiner: Patricia Ann George	
Confirmation No. 2261	
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RESPONSE TO RESTRICTION REQUIREMENT AND AMENDMENT

MS Amendment Commissioner for Patents P.O. Box 1450 Alexandria, Virginia 22313-1450

Commissioner:

In response to the restriction requirement imposed in the office action mailed on July 6, 2005, applicants elect Group I, claims 1-9, without traverse and submit the following amendment to clarify the claimed invention.

Amendments to the specification appear on page 2 of this paper.

Amendments to the claims and a complete listing of the claims begins on page 3 of this paper.

Remarks appear on page 4 of this paper.